

Application No: 10/722,729
Response dated 2/15/06
Response to Notice of Drawing Inconsistency
With Specification Mailed 1/24/06

In re application of:

Bright et al.

Application No: 10/722,729

Filed: November 25, 2003

For: APPARATUS FOR CONTROLLING WAFER
TEMPERATURE IN CHEMICAL MECHANICAL
POLISHING

IFW
PATENT

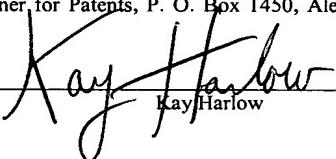
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

) Attorney Docket No: LAM2P318C
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Examiner: G.B.M. Nguyen
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Group Art Unit: 3723
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Date: February 15, 2006
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CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail to: Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22313-1450 on February 15, 2006.

Signed:


Kay Harlow

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Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Letter to Office of Patent Publication/Publishing Division
Response to Notice of Drawing Inconsistency With Specification

In response to the Notice of Drawing Inconsistency With Specification mailed 1/24/06, which set a 30 day period for response, please amend the specification of the captioned application as set forth on page 2 of this paper and consider the Remarks on page 3 of this paper.